

PATENT  
ATTORNEY DOCKET NO.: 053785-5148

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:

Seok-Woo LEE

Application No.: 10/648,401

Filed: August 27, 2003

For: METHOD OF FABRICATING TOP  
GATE TYPE THIN FILM TRANSISTOR  
HAVING A LOW TEMPERATURE  
POLYSILICON

Confirmation No.: 5327

Group Art Unit: 2812

Examiner: S. Isaac

## Mail Stop Amendment

Commissioner for Patents  
U.S. Patent and Trademark Office  
2011 South Clark Place  
Customer Window, **Mail Stop Amendment**  
Crystal Plaza Two, Lobby, Room 1B03  
Arlington, VA 22202

Sir:

**AMENDMENT**

In response to the Office Action dated August 3, 2004, the period for response to which extends through November 3, 2004, please amend the above-identified application as follows:

11/01/2004 BABRAHA1 00000055 500310 10648401

01 FC:1202 18.00 DA